

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	16650	(electroplat\$10 or electrodeposit\$10 or eelctroly\$10 or electrochem\$10) near3 (cu or copper)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	AND	ON	2005/11/15 09:09
L2	629	l1 and ((high or low) near3 acid)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	AND	ON	2005/11/15 09:09
L3	384	l2 and ((high or low) near3 (copper or metal or cu))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	AND	ON	2005/11/15 09:09
L4	41	l3 and suppressor\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	AND	ON	2005/11/15 09:10
L5	38	l4 and accelerator\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	AND	ON	2005/11/15 09:10